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240 County Road Ipswich, MA 01938-2723 Tel 978-927-5054 Fax 978-921-1350 www.neb.com info@neb.com

New England Biolabs Certificate of Analysis

Product Name:	NEBNext® Poly(A) mRNA Magnetic Isolation Module
Catalog Number:	E7490L
Lot Number:	10042215
Expiration Date:	06/2021
Storage Temperature:	4°C
Specification Version:	PS-E7490S/L v1.0

NEBNext® Poly(A) mRNA Magnetic Isolation Module Component List			
NEB Part Number	Component Description	Lot Number	Individual QC Result
E7499AAVIAL	NEBNext® Oligo dT(25) Magnetic Beads	10042220	Pass
E7496AAVIAL	NEBNext® Tris Buffer	10042219	Pass
E7495AAVIAL	Nuclease-free Water	10042218	Pass
E7493AAVIAL	NEBNext® Wash Buffer	10042217	Pass
E7492AAVIAL	NEBNext® RNA Binding Buffer (2X)	10042216	Pass

Assay Name/Specification	Lot # 10042215
* Individual Product Component Note Standard Quality Control Tests are performed for each component included in NEBNext®	Pass
Poly(A) mRNA Magnetic Isolation Module and meet the designated specifications.	
Functional Testing (Poly(A) Isolation)	Pass
The NEBNext® Poly(A) Isolation Module is functionally validated using commercially	
available human RNA (e.g. UHRR). After treatment using the kit's minimum and maximum input requirements, RNA yield is assessed by Bioanalyzer. Libraries made from	
previous and current lots, using the minimum and maximum input amounts are sequenced	
together on the same Illumina® flow cell and compared across various metrics	
including library yield, individual transcript abundance correlations, 5'-3'	
transcript coverage, and fraction of reads mapping to a reference. This method	
produces libraries with less than 10% rRNA.	

This product has been tested and shown to be in compliance with all specifications.





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Christine Sumner Production Scientist 04 Oct 2019

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Michael Tonello Packaging Quality Control Inspector 04 Oct 2019

